

#16/D  
5/9/03  
Muller

Attorney's Docket No.: 042390P9859

Patent



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application of:

Lawrence D. Wong

U.S. Serial No: 09/745,705

Examiner: Vu, Hung K.

Filed: December 21, 2000

Art Unit: 2811

For: Structural Reinforcement of Highly  
Porous Low K Dielectric Films by  
ILD Posts

Commissioner for Patents  
Washington, D.C. 20231

**AMENDMENT AND RESPONSE**

Dear Sir:

In response to the Office Action mailed January 30, 2003, Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

**FIRST CLASS CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Assistant Commissioner of Patents, Washington, D.C. 20231

On April 25, 2003  
Date of Deposit

Teresa Edwards  
Name of Person Mailing Correspondence

Teresa Edwards April 25, 2003  
Signature Date

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